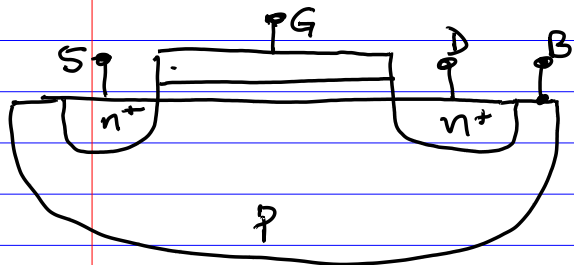


# Electrónica Fundamental

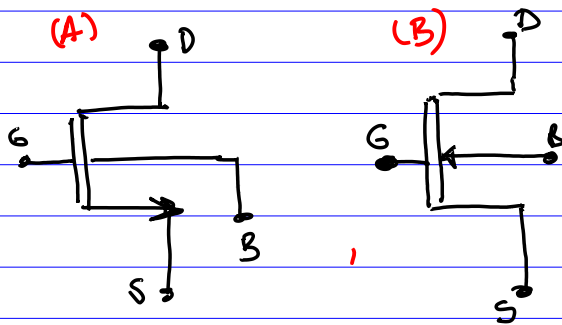
Transistor MOS  
Práctico 5

# Dispositivo MOS

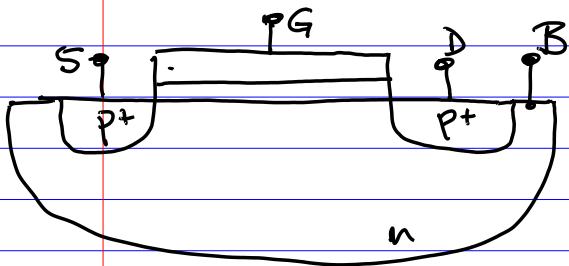
- canal n



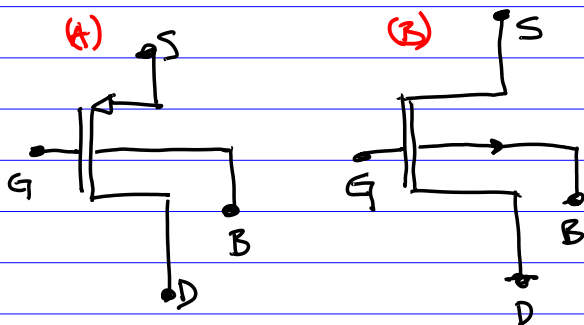
Símbolos



- canal p

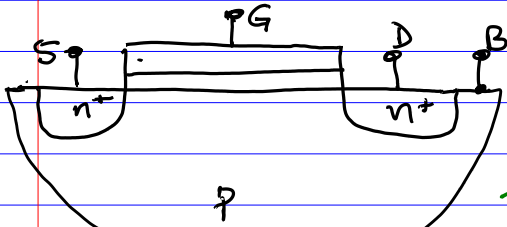


Símbolos



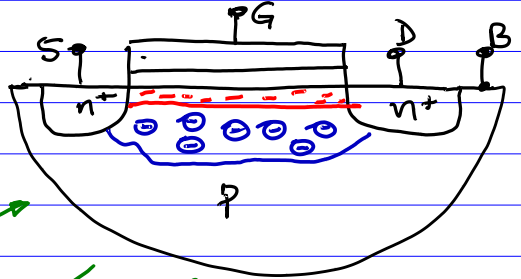
# Regiones de Operación

(0) transistor cortado



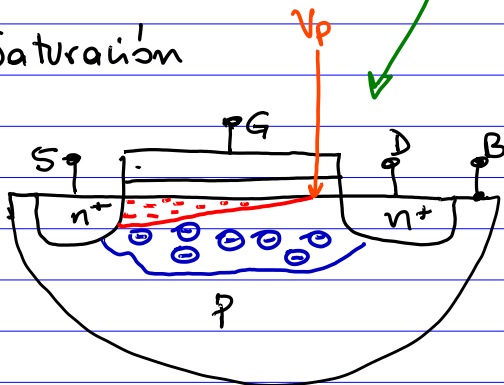
$$V_G = V_D = V_S = V_B = 0$$

(1) Zona lineal



$$V_D \approx V_B = V_S = 0 \\ V_G > 0 \quad (V_G > V_{to})$$

(2) Zona Saturación



$V_p$ : Voltage de Pinch-off

Voltage en el canal en el cual la carga de inversión se anula.

$$V_B = V_S = 0 \\ V_D > 0 \quad (V_G > V_{to})$$

$$V_p = f(V_{GB})$$

$$V_p = \frac{V_{GB} - V_{to}}{1 + \delta}$$

Ver hoja ec. transistor MOS

## Parámetros generales:

$\mu$ : Movilidad de los portadores (electrones para nMOS y huecos para pMOS)

$C_{ox}$ : Capacidad del óxido por unidad de área (igual a  $\epsilon_{ox}/t_{ox}$ , siendo  $\epsilon_{ox}$  la constante dieléctrica del óxido y  $t_{ox}$  el espesor del óxido)

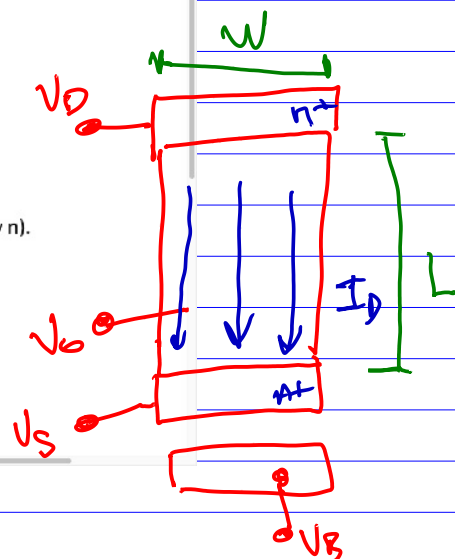
W: ancho del canal

L: largo del canal

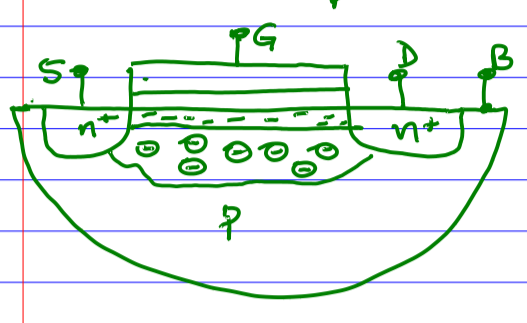
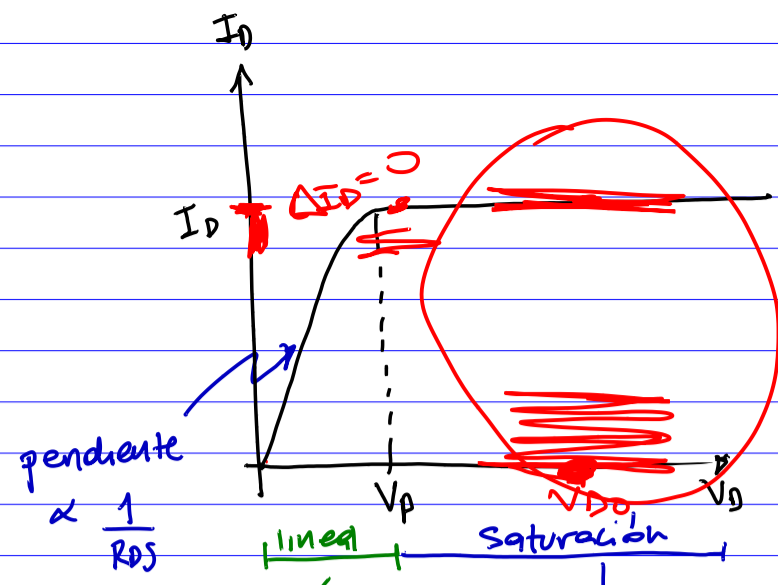
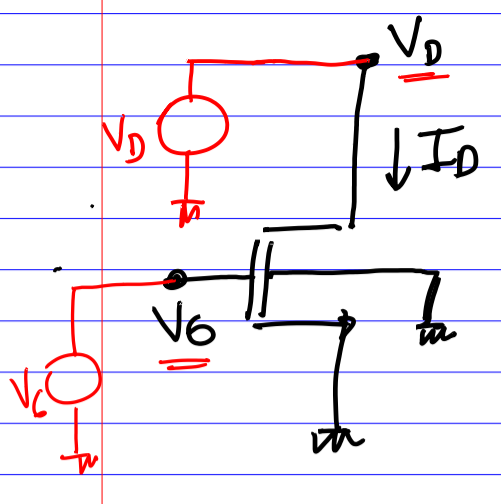
$$\beta = \mu \cdot C_{ox} \cdot \frac{W}{L}$$

$V_{to}$ : tensión umbral a tensión source sustrato nula

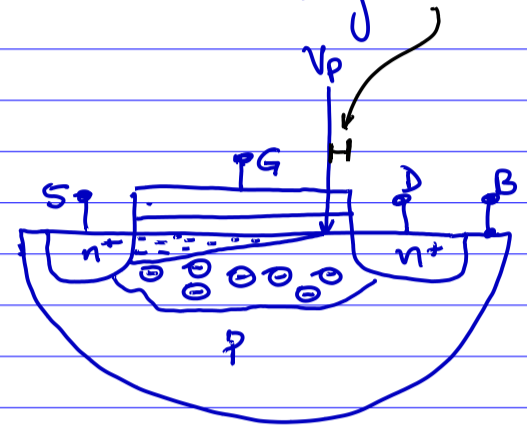
$\delta$ : parámetro de linealización del efecto de sustrato; ( $(1+\delta)$  también es denominado  $\lambda$  y  $n$ ).



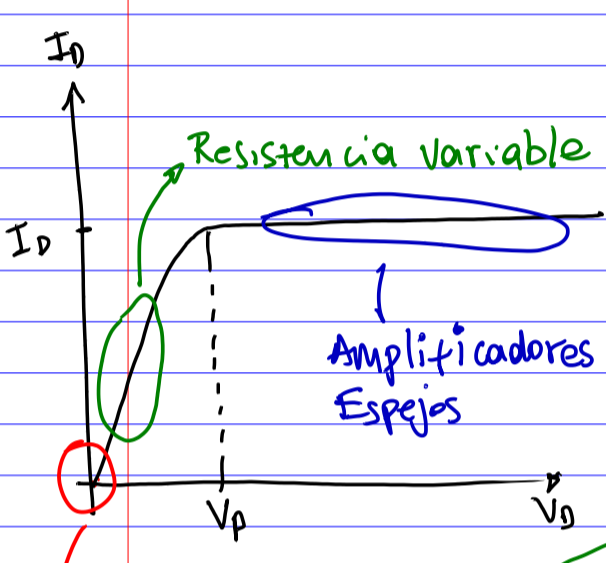
# Ensayo NMOS



Existe carga de inversion ( $Q_i$ ) de source (s) a drain (D)



## Ecuaciones



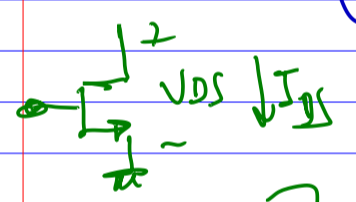
Zona Lineal:

$$I_D = \beta \left[ (V_G - V_{t0})(V_D - V_S) - \frac{(1+\delta)}{2} (V_D^2 - V_S^2) \right]$$

Condiciones:  $V_S < V_P \Leftrightarrow V_G > V_{t0} + (1+\delta)V_S$   
 $V_D < V_P$

Ver hoja de ecuaciones

$I_D \propto \beta (V_{GS} - V_{to}) V_{DS}$



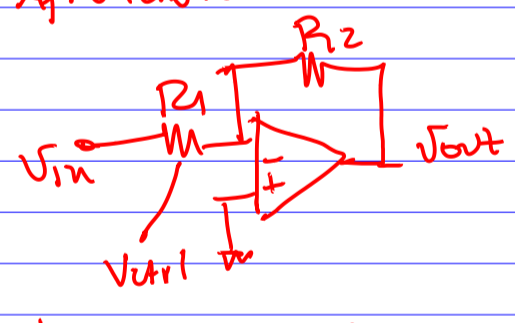
$$R_{DS} = \frac{V_{DS}}{I_{DS}} \cong \frac{1}{\beta (V_{GS} - V_{to})}$$

$$\cong \frac{1}{R_{DS}}$$

$$\frac{\partial I_D}{\partial V_{DS}} \Big|_{V_{GS} = \text{const}} = \beta (V_{GS} - V_{to})$$

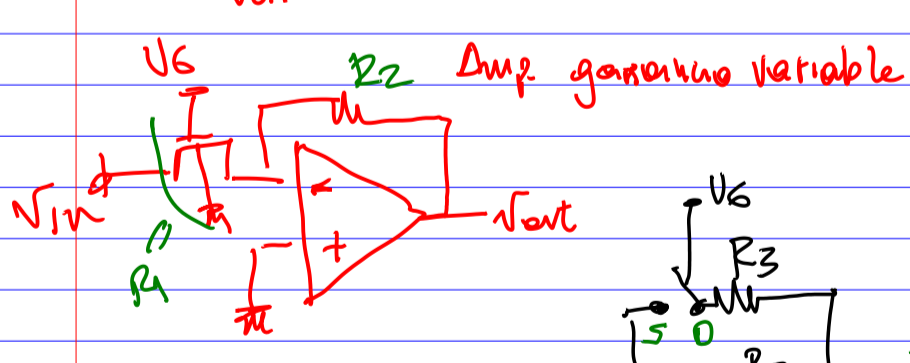
$R_{DS} = f(V_{GS})$

## Aplicación



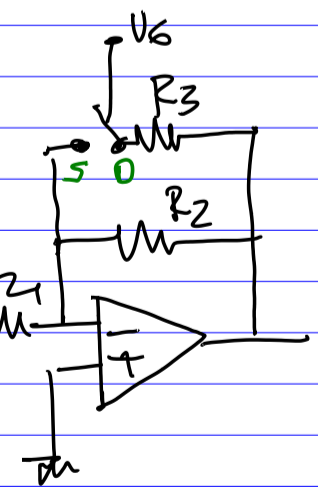
$$\frac{V_{out}}{V_{in}} = -\frac{R_2}{R_1}$$

$f(V_{GS})$



## Ejemplo 2

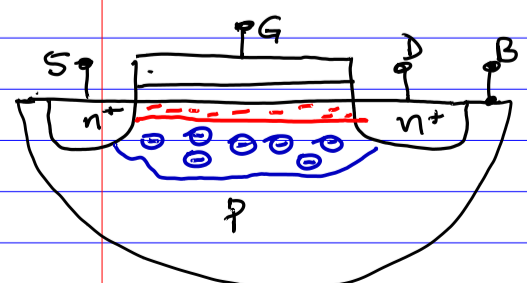
Amp ganancia variable usando llave



$V_G > V_{to} \rightarrow$   
 $gain = -\frac{R_2 \parallel R_3}{R_1}$

$V_G < V_{to}$

$$gain = -\frac{R_2}{R_1}$$

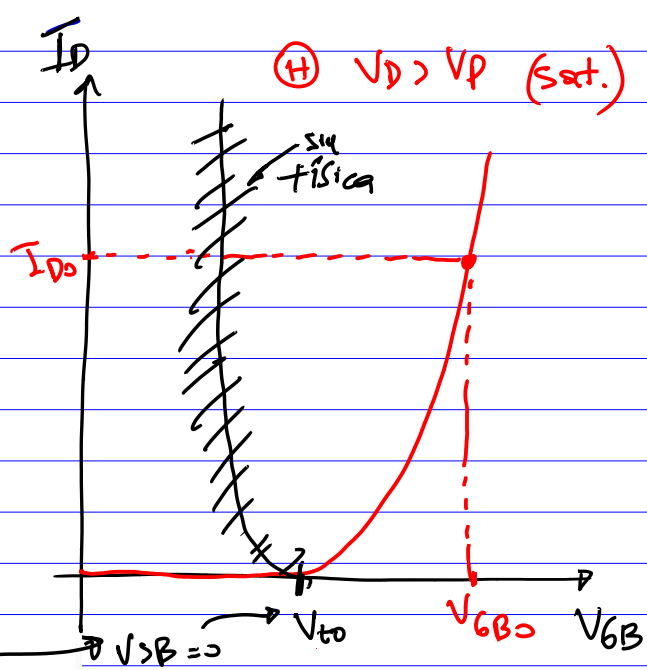
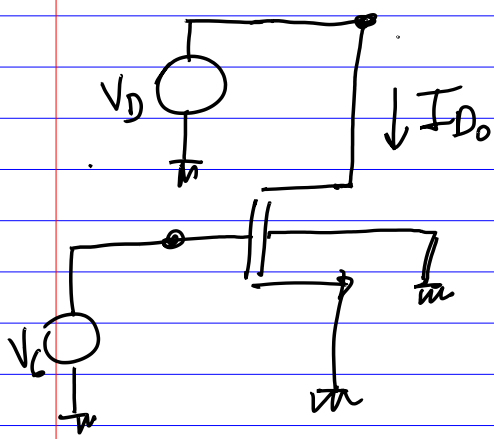


Bulk = V\_SS

$\Rightarrow R_{on} \ll R_3$

como diseñador

# Ensayo NMOS (II)



Zona Saturación:

$$I_D = \frac{\beta}{2(1+\delta)} (V_G - V_{t0} - (1+\delta)V_S)^2$$

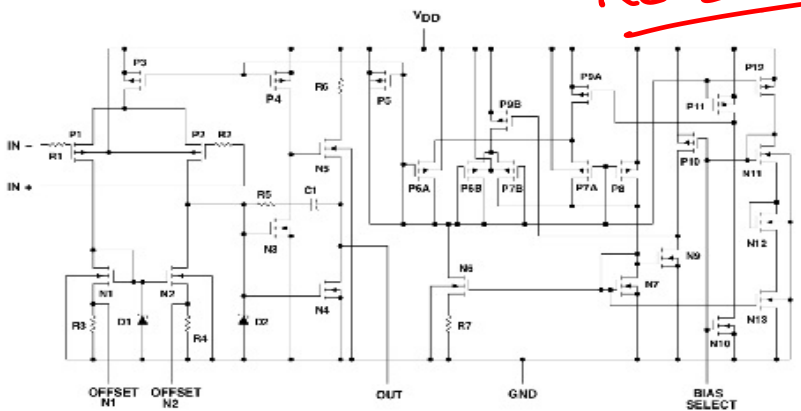
Condiciones:  $V_S < V_P \Leftrightarrow V_G > V_{t0} + (1+\delta)V_S$   
 $V_D \geq V_P$

$I_D$  no depende de  $V_D$

Amplificación

TLC 271

equivalent schematic



## Hoja de ecuaciones.

3 sets de ecuaciones para

$$I_D = f(V_G, V_S, V_B, V_D)$$

NMOS Referido a  $V_B$  (1)

NMOS Ref. a  $V_S$  (2)

PMOS Ref. a  $V_B$  (3)

Ejemplo pasar de (1) a (2)

$$I_D = \frac{\beta}{2(1+\delta)} (V_{GB} - V_{t0} - (1+\delta)V_{SB})^2 \quad \text{de (1)} \quad \text{© Sat.}$$

↙ cambio variable

$$I_D = \frac{\beta}{2(1+\delta)} ( \underbrace{V_{GB} - V_{SB}}_{V_{GS}} - \underbrace{(V_{t0} + \delta V_{SB})}_{V_T} )^2$$

$$I_D = \frac{\beta}{2(1+\delta)} (V_{GS} - V_T)^2 \quad \text{de (2)} \quad \text{© Sat.}$$

**Ejercicio 2 (5.56)**

El objetivo de este ejercicio es estudiar y ejercitar las ecuaciones del transistor MOS en circuitos sencillos. Los circuitos mostrados en las Figuras 2.1, 2.2 y 2.3 se caracterizan por  $V_{t0} = 0.8V$ ,  $\beta = 0.5mA/V^2$  y  $\delta = 0$ .

- (a) Calcule cuánto valen  $V_1$  y  $V_5$
- (b) Muestre que el transistor de la Figura 2.3 siempre está saturado y calcule el valor de  $V_6$ .

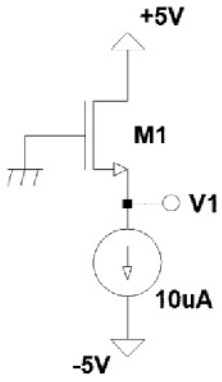


Figura 2.1

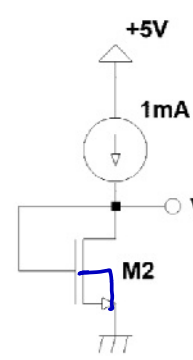


Figura 2.2

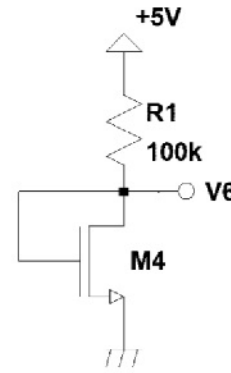
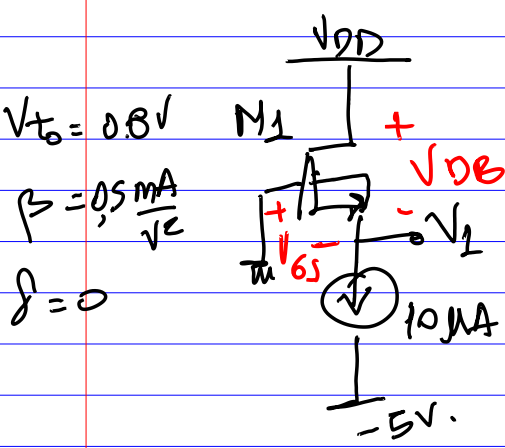


Figura 2.3



$V_G = 0$   
 $V_D = V_{DD}$



⊕ M1: Saturado?

$$I_D = \frac{\beta}{2(1+\delta)} (V_{GB} - V_{t0} - (1+\delta)V_S)^2$$

$$I_D = \frac{\beta}{2} (V_{GB} - V_{t0})^2$$

M1: Saturado?

$V_p > V_{SB}$

$V_p = \frac{V_{GB} - V_{t0}}{1+\delta} = V_{GB} - V_{t0}$

$V_p = \sqrt{\frac{2I_D}{\beta}}$

$V_{GB} > V_{t0} = 0.8V$

$V_{GB} = V_G - V_B = 0 - 0 = 0$

$\Rightarrow V_p > V_{SB}$

cond. de canal.

$V_p < V_{DB}$ ?

$V_p = V_{GB} - V_{t0} < V_{DB} \Rightarrow -V_{t0} < V_{DB} - V_{GB} = V_D - V_G - (V_G - V_B)$

$\Rightarrow -V_{t0} < V_{DD}$

$V_p < V_{DB}$

de  $*y*$   $\Rightarrow$  saturación OK!

$V_1 = ?$

$I_D = \frac{\beta}{2} (V_{GB} - V_{t0})^2$

$V_{GB} = V_{t0} + \sqrt{\frac{2I_D}{\beta}}$

$V_{GB} = 1V$

$V_1 = V_G - V_{GB} = -1V$

termino de verificar que M1 está saturado

$V_{DB} = V_{DD} - V_1 = 6V$

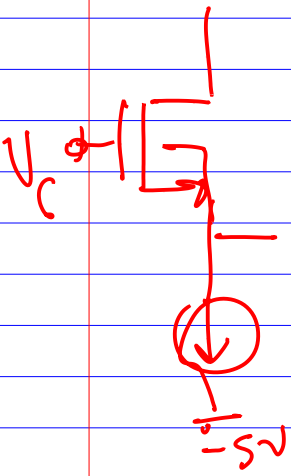
$V_p = 200mV$

$\rightarrow V_{DB} > V_p$  OK!

M1 saturado

Duda surgida en clase

Porque  $V_1 = V_G - V_{GB}$ ?



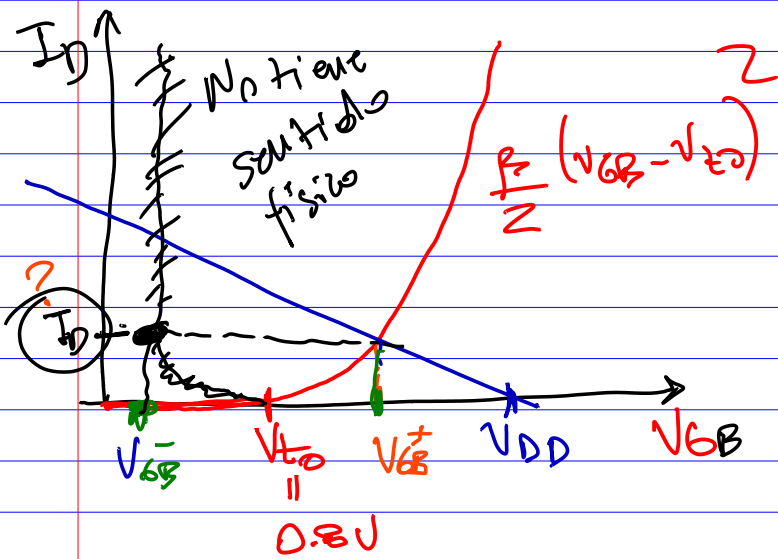
$V_1 = V_G - V_{GB} = V_G - (V_G + V_B) = -V_B$

$\rightarrow V_1 = V_B$







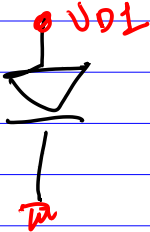
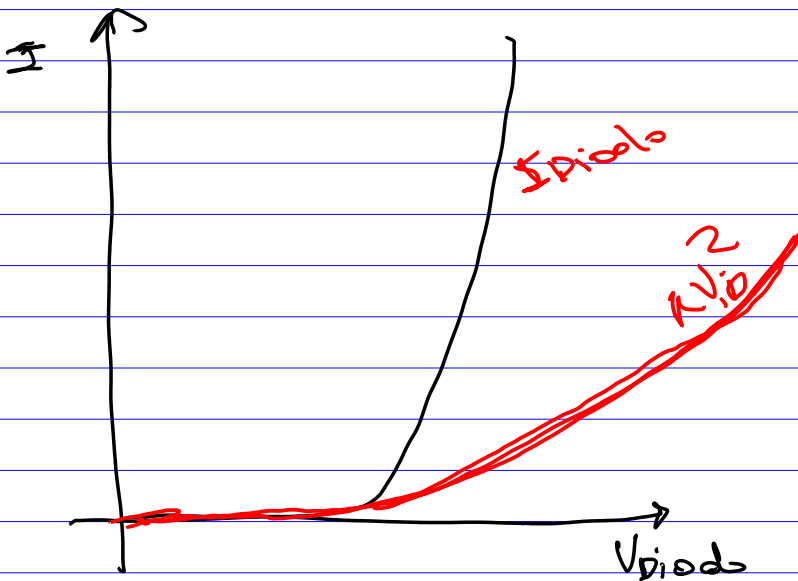


$$V_{GB}^+ = 1.19V$$

$$V_{GB}^- = 369mV$$

$$I_D = \frac{R}{Z} (V_{GB} - V_{t0})$$

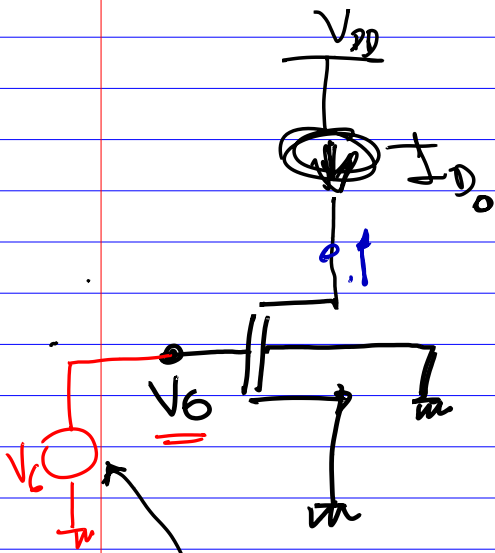
$V_{t0} = 0.8V$



$$I_{Diodes} = I_S \left( e^{\frac{V_{Diodes}}{nV_T}} - 1 \right)$$

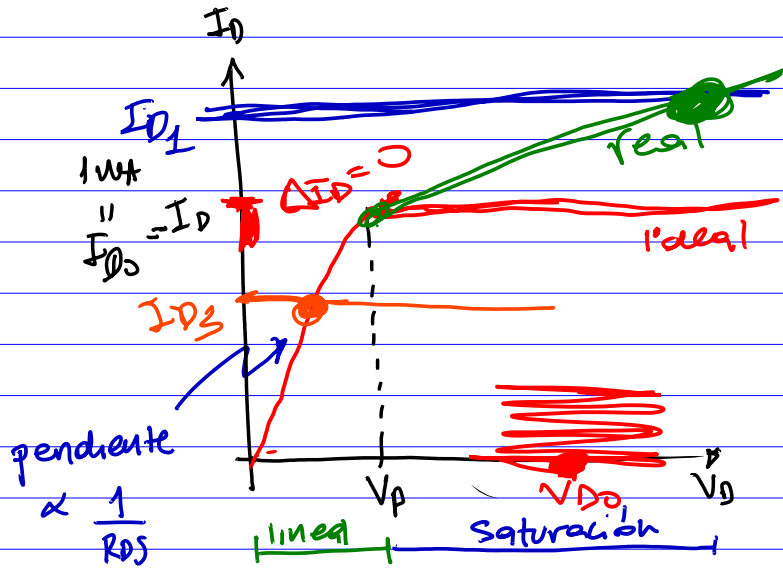


# Experimento



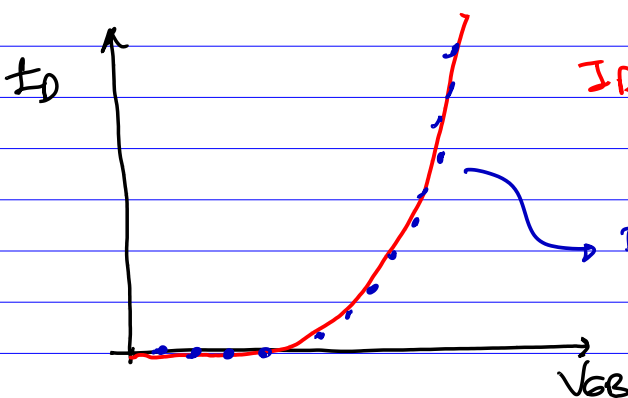
si  $V_{GS} = cte$

$V_p = cte.$



$$V_p = \frac{V_{GS} - V_{to}}{1 + \beta}$$

## Prueba de Lab



$$I_D = \frac{\beta}{2(1 + \beta)} (V_{GS} - V_{to})^2$$

pts extraidos del spice

